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# Pits and Pores 4: New Materials and Applications – In Memory of Ulrich Gösele

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## Editors:

### D. Lockwood

National Research Council Canada  
Ottawa, Ontario, Canada

### R. Boukherroub

Université Lille1  
Villeneuve d'Ascq, France

### Y. Ogata

Kyoto University  
Kyoto, Japan

### P. Schmuki

University of Erlangen-Nuremberg  
Erlangen, Germany

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